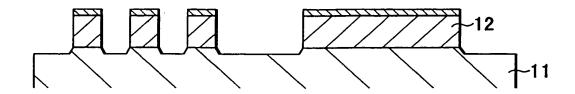


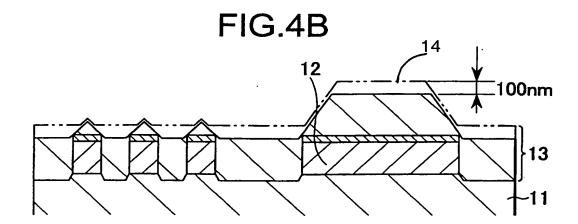
## PRODUCTION METHOD OF SEMICONDUCTOR DEVICE Inventor: Yoshiyuki Tanaka et al. Docket No. 075834.00111

Robert J. Depke, Holland & Knight LLC - (312) 263-3600

4/11

FIG.4A







PRODUCTION METHOD OF SEMICONDUCTOR DEVICE Inventor: Yoshiyuki Tanaka et al. Docket No. 075834.00111

Robert J. Depke, Holland & Knight LLC - (312) 263-3600

## PRIOR ART

6/11

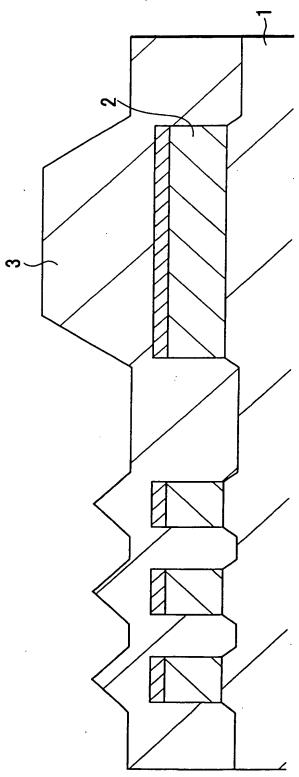


FIG.6

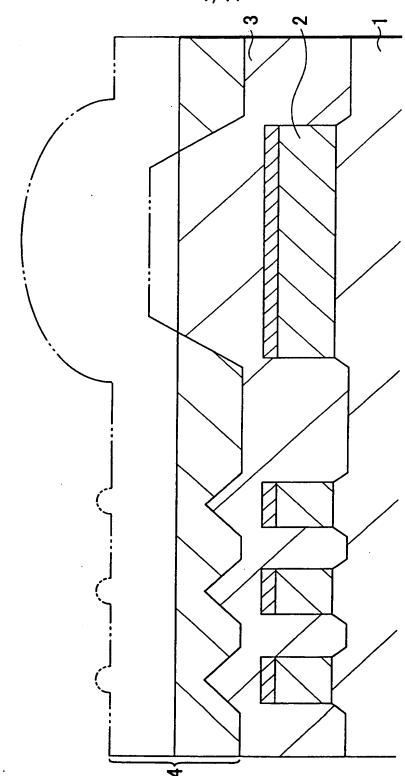


PRODUCTION METHOD OF SEMICONDUCTOR DEVICE Inventor: Yoshiyuki Tanaka et al. Docket No. 075834.00111

Robert J. Depke, Holland & Knight LLC - (312) 263-3600

## PRIOR ART

7/11

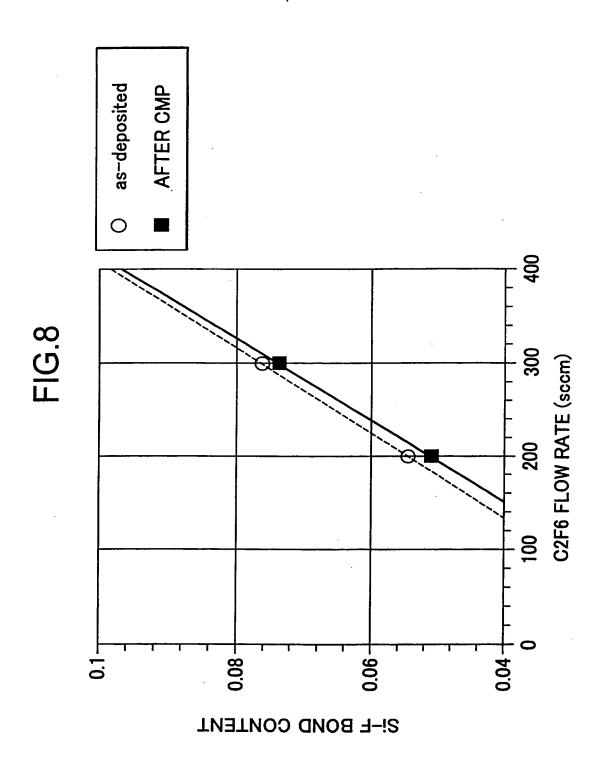




## → PRODUCTION METHOD OF SEMICONDUCTOR DEVICE Inventor: Yoshiyuki Tanaka et al. Docket No. 075834.00111

Robert J. Depke, Holland & Knight LLC - (312) 263-3600

### PRIOR ART 8/11

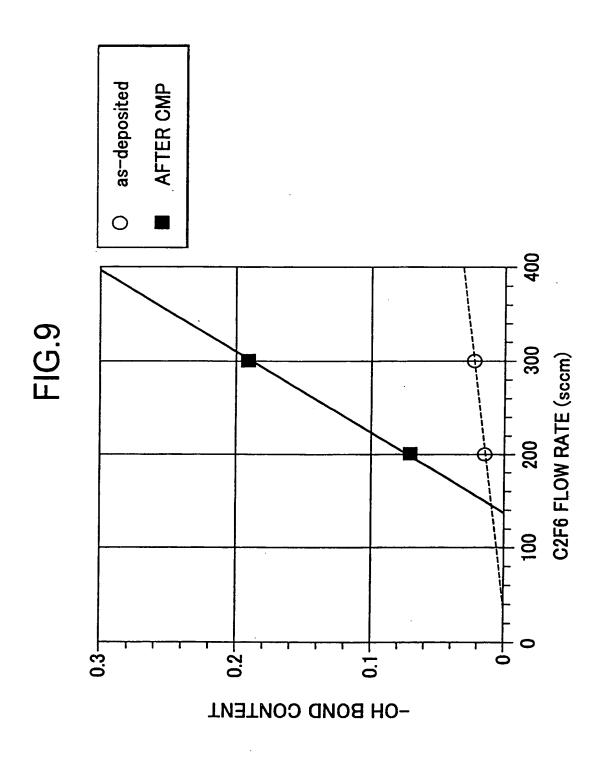




## - PRODUCTION METHOD OF SEMICONDUCTOR DEVICE Inventor: Yoshiyuki Tanaka et al. Docket No. 075834.00111

Robert J. Depke, Holland & Knight LLC - (312) 263-3600

# PRIOR ART 9/11



#### - PRODUCTION METHOD OF SEMICONDUCTOR DEVICE Inventor: Yoshiyuki Tanaka et al. Docket No. 075834.00111

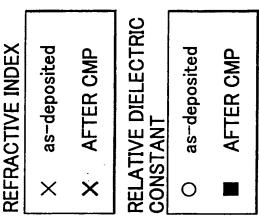
Robert J. Depke, Holland & Knight LLC - (312) 263-3600

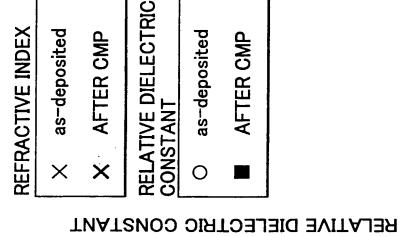
# 10/11

C2F6 FLOW RATE (sccm)

1.42

REFRACTIVE INDEX





4.6



FIG.10

PRIOR ART



PRODUCTION METHOD OF SEMICONDUCTOR DEVICE Inventor: Yoshiyuki Tanaka et al.
Docket No. 075834.00111

Robert J. Depke, Holland & Knight LLC - (312) 263-3600

# PRIOR ART 11/11

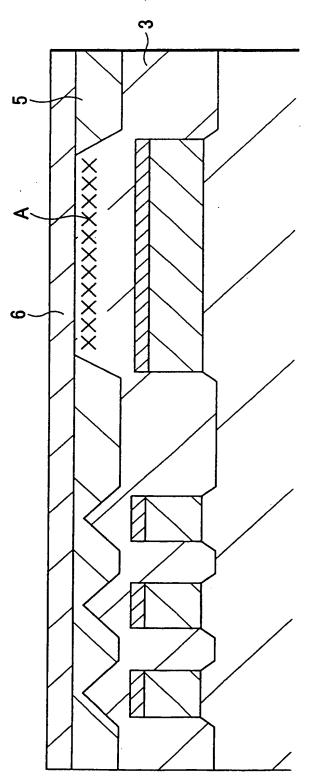


FIG 11